

## Atomic Manipulation on a Scanning Transmission Electron Microscope Platform using Real-Time Image Processing and Feedback

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Fabrication of atomic scale structures remains the ultimate goal of nanotechnology. The reigning paradigms have been scanning probe microscopy (SPM) and synthesis. SPM assembly dates to seminal experiments by Don Eigler, who demonstrated single atom manipulation. However, stability and throughput remain issues. Discuss here are research activity towards the next paradigm — the use of the atomically focused beam of a scanning transmission electron microscope (STEM) to control and direct matter on atomic scales. Traditionally, STEM's are perceived only as imaging tools and beam induced modifications as undesirable beam damage. Our team and several groups worldwide have demonstrated that beam induced modifications can be more precise and controllable. We have demonstrated ordering of oxygen vacancies, single defect formation in 2D materials including adding and moving dopants within a lattice [1-4], and beam induced migration of single interstitials in diamond like materials. What is remarkable is that these changes often involve one atom or small group of atoms and can be monitored real-time with atomic resolution.

Critical to controlled manipulation of matter at the atomic scale is the ability to have an automated system to process multiple streams of data in real-time, operate on the processed data, and make fast decisions based on this information to correctly set optimal conditions (such as beam position and trajectory) to induce the desired transformation. Further complications arise since one uses the same beam to both image material and change it. Therefore, it is necessary to develop imaging methods that introduce as small of an electron dose as possible to the material during imaging while still providing sufficient reliability as well as develop schemes to modify materials with maximal effectiveness during atomic scale manipulation. Several examples will be introduced of beam-induced fabrication on the atomic level, and demonstration of how beam control, rapid image analytics, better insight through modelling, and image-based feedback allows for controlling matter on the atomic level.

### References:

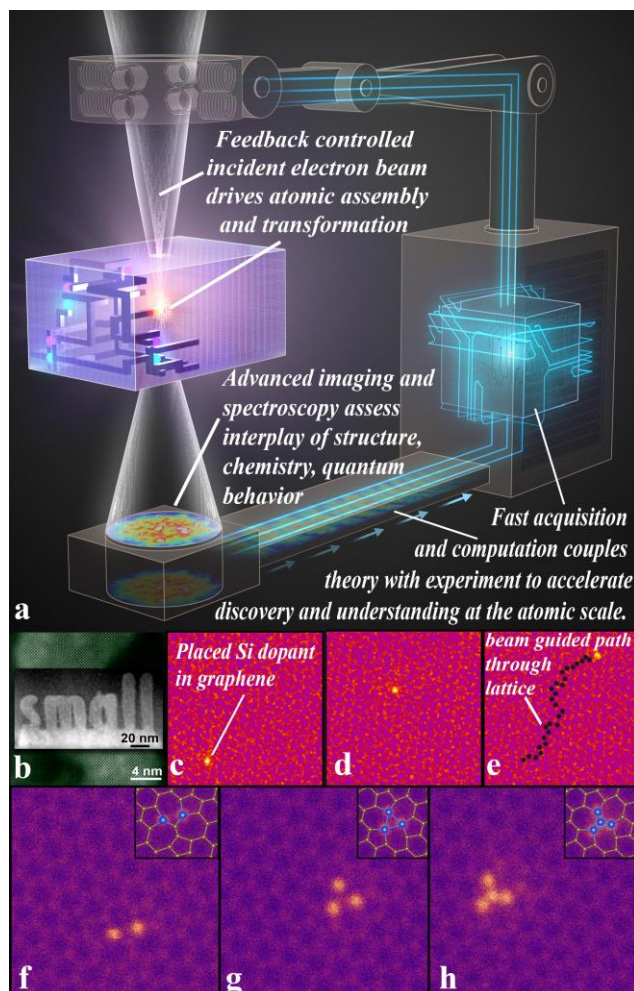
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**Figure 1.** Information Flow for Directed Atomic Assembly in STEM. (a) Enhanced STEMs enable building and editing of atomic assemblies and assessment of their chemical, physical, and quantum properties [5]. (b) Layer-by-layer atomic scale sculpting [6]. (c-e) Directed doping and guided motion of Si atom through graphene lattice. (f-h) Beam directed atom-by-atom fabrication of Si dimer, trimer, and tetramer.